Customer ID: 25094

IN THE TITLE

Please change the title to:

GATED FABRICATION OF NANOSTRUCTURE FIELD EMISSION CATHODE MATERIAL WITHIN A DEVICE

IN THE CLAIMS:

Please cancel claims 1-8 without prejudice or disclaimer to the subject matter recited therein:

- 1-8. (Canceled)
- 9. (Currently Amended) A gated field emission device made by the <u>a</u> method of claim 1 comprising:

growing a substantially vertically aligned carbon nanostructure, the substantially vertically aligned carbon nanostructure coupled to a substrate;

- covering at least a portion of the substantially vertically aligned carbon nanostructure with a dielectric;
- forming a gate, the gate coupled to the dielectric; and
- releasing the substantially vertically aligned carbon nanostructure by forming an aperture in the gate and removing a portion of the dielectric,

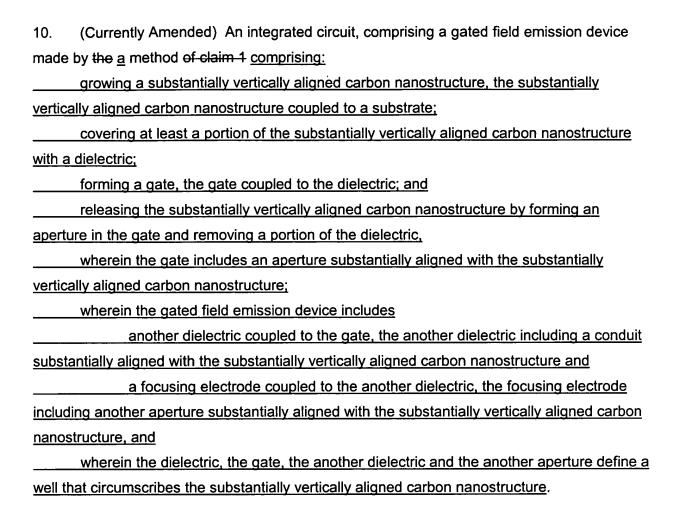
wherein the gate includes an aperture substantially aligned with the substantially vertically aligned carbon nanostructure;

wherein the gated field emission device includes

another dielectric coupled to the gate, the another dielectric including a conduit substantially aligned with the substantially vertically aligned carbon nanostructure and

a focusing electrode coupled to the another dielectric, the focusing electrode including another aperture substantially aligned with the substantially vertically aligned carbon nanostructure, and

wherein the dielectric, the gate, the another dielectric and the another aperture define a well that circumscribes the substantially vertically aligned carbon nanostructure.



- 11. (Currently Amended) An apparatus, comprising:
 - a substantially vertically aligned carbon nanostructure coupled to a substrate;
- a dielectric coupled to the substrate and surrounding at least a portion of the substantially vertically aligned carbon nanostructure;
- a gate coupled to the dielectric, the gate including an aperture substantially aligned with the substantially vertically aligned carbon nanostructure;

another dielectric coupled to the gate, the another dielectric including a conduit substantially aligned with the substantially vertically aligned carbon nanostructure; and

a focusing electrode coupled to the another dielectric, the focusing electrode including another aperture substantially aligned with the substantially vertically aligned carbon nanostructure,

wherein the dielectric, the gate, the another dielectric and the another aperture define a well that circumscribes the substantially vertically aligned carbon nanostructure.

- 12. (Original) The apparatus of claim 11, wherein the substantially vertically aligned carbon nanostructure includes a vertically aligned carbon nanofiber.
- 13. (Original) The apparatus of claim 11, wherein the focusing electrode composes an electrostatic focusing lens.
- 14. (Original) The apparatus of claim 11, wherein the dielectric surrounds a single substantially vertically aligned carbon nanostructure.
- 15. (Original) The apparatus of claim 11, wherein the aperture is formed by chemical mechanical polishing.
- 16. (Original) The apparatus of claim 11, wherein at least a portion of the well is formed by reactive ion etching.
- 17. (Original) The apparatus of claim 11, wherein the focusing electrode includes another aperture that is substantially aligned with the aperture of the gate.
- 18. (Original) A method for emitting electrons which comprises utilizing the apparatus of claim 11.
- 19. (Original) A gated field emission device, comprising the apparatus of claim 11.
- 20. (Original) An integrated circuit, comprising the apparatus of claim 11.
- 21. (Original) A circuit board, comprising the integrated circuit of claim 20.